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Do Kyung Hwang received his B.S. and Ph.D. degree in materials science and engineering and applied physics from Yonsei University in 2003 and 2008, respectively. From 2008 to 2009, he was a postdoctoral associate at Korea Institute of Science and Technology (KIST). From 2009 to 2012, he was a postdoctoral fellow at Georgia Institute of Science and Technology where he focused on solution processed organic field-effect transistor. He is currently a senior researcher for Center of Opto-Electronic Materials and Devices in Korea Institute of Science and Technology (KIST). His current research interest includes fundamental and applied aspects of organic, metal oxide, and low-dimensional semiconductor materials and various electronic/optoelectronic applications.